Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2318	mask near5 nitride with gate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/07 07:38
L2	2690	mask\$3 near5 nitride with gate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/07 07:38
L3	517	2 same sidewall\$1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/07 07:39
L4	255	3 and silicide with gate\$1′	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/07 07:42
L5	233	4 and (remov\$3 etch\$3) near5 mask\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/07 07:41
L6	59	3 same silicide with gate\$1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/02/07 07:42